

ABSTRACT OF THE DISCLOSURE

FILM STRUCTURE BODY AND METHOD FOR MANUFACTURING THE SAME

A film structure body has: a substrate that is a silicon substrate including an upper surface composed of a (100) plane; an orientation film including a zirconium oxide film that is cubic crystal (100)-oriented on the upper surface; and a conductive film including a platinum film that is cubic crystal (100)-oriented on the orientation film.

(No drawing to be published)